Int. J. Electrochem. Sci., 8 **(2013)** 7479 - 7480

International Journal of
ELECTROCHEMICAL
SCIENCE
www.electrochemsci.org

Erratum to "Electrochemical Behavior of Corrosion Resistance of X65/Inconel 625 Welded Joints, *Int. J. Electrochem. Sci.,* 8(2013) 2069 – 2079"

L.Y. Xu, M. Li, H.Y. Jing and Y.D. Han

[1]School of Materials Science and Engineering, Tianjin University, Tianjin 300072, PR China
[2]Tianjin Key Laboratory of Advanced Joining Technology, Tianjin 300072, PR China

1 May 2013

There are some mistakes in the published paper regarding used references. In this erratum we give correct list of all references.

1. Y.S. Choi, S. Nesic, and D.Young,: *Environ. Sci. Technol*, 44 (2010) 9233.
2. D. A. Lopez, S.N. Simison, and S.R. de Sanchez,: *Electrochim. Acta*, 48 (2003) 845.
3. M.B. Kermani, and A. Morshed,: *Corrosion*, 59 (2003) 659.
4. Y. Watanabe, Y. Inaguma, and H. Sato,: *Mater. Lett.,* 65 (2011) 467.
5. T. Kannan and N. Murugan,: *J. Mater. Process. Technol.,* 176 (2006) 230.
6. E. Gamboa, V. Linton, and M. Law,: *Int. J. Fatigue*, 30 (2008) 850.
7. D. A. Walsh, L. E. Li, M.S. Bakare, and K.T.Voisey,: *Electrochim. Acta*, 54 (2009) 4647.
8. Z.F. Yin, W.Z. Zhao, W.Y. Lai, and X.H. Zhao,: *Corros. Sci.,* 51 (2009) 1702.
9. H. Bouazaze, F. Huet, and R.P. Nogueira,: *Electrochim. Acta,* 50 (2005) 2081.
10. F. Huet, and R.P. Nogueira, *Corrosion*, 59 (2003) 747.
11. G. A. Zhang, and Y. F. Cheng,: *Corros. Sci.,* 51 (2009) 901.
12. A. Neville, M. Reyes, T. Hodgkiess, and A. Gledhill, *Wear*, 238 (2000) 138.
13. N. Ahmed, M.S. Bakare, D.G. McCartney, and K.T. Voisey,: *Surf. Coat. Technol.*, 204 (2010) 2294.
14. P.R. Ambriz, D. Chicot, N. Benseddiq, G. Mesmacque, and S.D. de la Torre,: *Eur. J. Mech. A Solids,* 30 (2011) 307.
15. S. E. Ziemniak, and M. Hanson,: *Corros. Sci.*, 48 (2006) 498.

16. Z.F. Yin, W.Z. Zhao, W. Tian, Y.R. Feng, and C.X. Yin,: *J. Solid State Electrochem.*, 13 (2009) 1291.
17. H.X. Hu, Y.G.Zheng, and C.P. Qin,: *Nucl. Eng. Des*. 240 (2010) 2721.
18. A. Pardo, M.C. Merino, A.E. Coy, F. Viejo, R. Arrabal, and E. Matykina,: *Corros. Sci*., 50 (2008) 1796.
19. R. Bandy, and D.Van Rooyen,: *Corros. Sci*., 39 (1983) 227.
20. A. C. Lloyd, J. J. Noel, S. McIntyre and D. W. Shoesmith, *Electrochim. Acta,* 49 (2004) 3015.
21. R. Norling, and I. Olefjord,: *Wear*, 254 (2003) 173.
22. S.R. Allahkaram, P. Zakersafaee, and S.A.M. Haghgoo,: *Eng. Fail. Analysis*, 18 (2011)1108.
23. Janusz Adamiec,: *Mater. Charact*., 60 (2009) 1093.
24. L.Wegrelius, F. Falkenberg, and I. Olefjord,: *J. Electrochem. Soc*., 146 (1999) 1397.
25. G.O. Ilevbare, and G.T. Burstein, *Corros. Sci.,* 43 (2001) 485.
26. A. Schneider, D. Kuron, S. Hofman, and R. Kirchheim,: *Corros. Sci*., 31 (1990) 191.
27. I. Olefjord, and L. Wegrelius, : *Corros. Sci*., 38 (1996) 1203.
28. K. Sugimoto, and Y. Sawada,: *Corros. Sci.,* 32 (1976) 347.
29. K. Hashimoto, H. Katagiri, H. Habazaki, M. Yamasaki, A. Kawashima, K, Izumiya, K. Asami, S. Meguro,: *Electrochem. Chem. React. Amorphous Nanocrystalline Mater.,* 337 (2001) 1.